Electrical Characterization and Application of Very High Speed Vertical Cavity Surface Emitting Lasers (VCSELs)


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ABSTRACT
Vertical Cavity Surface Emitting Lasers (VCSELs) offer many benefits over conventional edge-emitting lasers including economical microelectronic batch processing, easy extension to 2-D arrays, and of interest here, very large intrinsic bandwidths due to reduced cavity volume. Results of electrical characterization of a 19 GHz bandwidth 850nm VCSEL are presented. Small-signal characterization and modeling of the frequency response and device impedance is presented. Large signal performance is studied using two-tone RF and high-speed digital measurements. Appropriate drive conditions for high-speed digital applications are demonstrated.

INTRODUCTION
Very high efficiency VCSELs with over 20 GHz electrical bandwidths have been demonstrated with several mW output power. These are believed to be the fastest laser diodes ever realized at 850 nm. Though this wavelength is not consistent with long-haul optical link needs, it is consistent with the Fibre Channel and ATM Forum standards and is in strong favor for economical short haul fiber optic links.

The small cavity volume of VCSELs allows for very large intrinsic bandwidths. By the careful minimization of electrical parasitics, we have successfully demonstrated VCSELs with bandwidths in excess of 20 GHz. [1] This has been achieved by using several novel process enhancements. Intrinsic device limits appear to be well in excess of 50 GHz. It appears that the present bandwidth is limited predominantly by thermal issues.

DEVICE STRUCTURE
A schematic diagram of the cross section of the high speed VCSEL is shown in Fig. 1. The VCSEL cavity is formed by MOVPE growth where an active region is appropriately positioned between two dielectric mirror stacks. The active region is comprised of five GaAs quantum wells. The mirrors are necessarily comprised of alternating layers of high and low Al fraction AlGaAs for high optical reflectivity. This need typically results in an undesirably high mirror resistance (due to heterojunction barriers) which significantly degrades device performance. To minimize this effect, a novel uniparabolic grading profile produced by MOVPE growth as well as careful doping considerations were used to greatly reduce the mirror resistance [2] To further minimize mirror resistance, the VCSEL was grown n-type up (see Fig. 1) to take advantage of the lower lateral resistance of the n-type material.

Another unique feature of these VCSELs is the use of a selective wet thermal oxidation used to convert an AlGaAs mirror layer to an insulating low index alumina film.[3] The low index of the resulting alumina layer yields excellent lateral...
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mode confinement and overlap with the electrical pump; and lasers with 50% power efficiency have been demonstrated.[4]

Shown in Fig. 2 is a microphotograph of an actual 4x4 μm² device. Contact to the device is achieved by coplanar contacts. These contact pads are fabricated on top of a 4 μm thick polyimide layer which results in a low pad capacitance of about 50 fF. To further reduce the total device capacitance, a proton implant was performed under the contact regions (see Fig. 1).

Fig. 2. Microphotograph of high-speed VCSEL. The VCSEL's 4x4 μm² aperture is the small dot seen at the end of the center strip.

All of the measurements in this paper were performed on-wafer using a standard RF probe and a lensed multimode fiber positioned normal to the DUT by using a Cascade Microtech lightwave probe. The light was detected using a 25 GHz bandwidth model 1431 New Focus detector.

Fig. 3 shows plots of the light in the fiber (estimated based on the detector's responsivity specification) and voltage for a 0 to 6 mA current bias range. Note the very low threshold current (=0.5 mA) and the low operating voltage.

SMALL-SIGNAL MODEL

Small-signal characterization was performed with an HP 8510 network analyzer using an LRM calibration for the impedance measurements and a simple response calibration along with correction for probe loss and detector response for the response measurements.

Plotted in Fig. 4 is the measured S11 for several different bias currents. Due to the small size of these VCSELs and the mirror resistance, electrical drive impedances are much higher than with conventional edge emitter lasers.

Fig. 4. Measured S11 of the VCSEL at 0, 1, 2, and 3 mA bias currents (0.045 to 25 GHz).

Fig. 5 shows the measured response along with corresponding fits using the small-signal model outlined in Fig. 6. A co-optimization was used to simultaneously fit the measured S11 and response. In general, the modeled S11 results (not shown in
Fig. 4 for clarity) were very similar to the measured. From a co-optimization at several bias conditions $C_p = 54 \, \text{fF}$, $R'_p = 16 \, \Omega$, and $R_m = 136 \, \Omega$. The active region's equivalent capacitance, $C_a$, and equivalent resistance, $R_a$, were found to be bias dependent with $R_a$ varying from $270 \, \Omega$ at 1 mA to $160 \, \Omega$ at 5 mA and $C_a$ varying from 67 fF at 1 mA to 106 fF at 5 mA. These values for $R_a$ may seem large as compared to a normal junction resistance, but this resistance includes a combination of lateral and spreading terms.

The differential light output, $I_o$, is modeled using the traditional damped resonator model. Fig. 7 shows a plot of the measured cutoff frequency, $f_{\text{3dB}}$, the relaxation frequency, $f_p$, and the resonance width $T/\pi$ (defined in Fig. 6) plotted against bias current. At low bias currents, from conventional rate equation analysis, the 3dB bandwidth is known to increase in proportion to the square root the drive current above threshold. For the data in Fig. 7, the resulting modulation current efficiency factor is about 15.2 GHz/mA. The resonant frequency, $f_p$, is seen to increase rapidly at low bias currents and then quickly saturate at about 3 mA to around 16 GHz. This is a clear indication of a limit due to heating in the device. A quadratic fit of the damping rate, $T$, against the resonant frequency, $f_p$, at resonant frequencies below 15 GHz, results in K factor of 95 pS which implies an intrinsic bandwidth in excess of 90 GHz. Such frequencies are not currently attainable due to thermal effects, and remaining device RC parasitics. If these issues could be minimized along with designs for single-mode operation at extended bias currents, it is believed that significant bandwidth increases could be realized.

Fig. 7. The cutoff frequency, $f_{\text{3dB}}$; the extracted relaxation frequency, $f_p$; and the extracted resonance width $T/\pi$ plotted versus bias current.

LARGE SIGNAL OPERATION

To evaluate large signal operation, two-tone tests and digital measurements were performed. Fig. 8 shows the result of a two-tone test performed at 5 GHz with a device bias current of 3.75 mA. The linear components (at 5 and 5.01 GHz) and the 3rd order inter-modulation components were seen to both increase at the proper rate (1dB/dB and 3dB/dB). The vertical scale in this plot represents the actual power levels measured on a spectrum analyzer. The scale is relative as the fiber coupling can be arbitrarily adjusted and hence absolute power measurements are difficult. Nevertheless, the intercept from the horizontal axis (6.5dBm) gives a good indication of suitable drive levels for low distortion analog link applications. The spurious free dynamic range for this fiber optic link is over 40 dB at optimal bias. This intercept is bias dependent with a measured values of 7 dBm, =16 dBm, and 6.8 dBm at bias currents of 1.25, 2.5 and 3.75 mA, respectively at 5 GHz. Measurements at the mid bias range, were difficult due to the small 3rd order component even when driving the device at power levels approaching the 1dB compression point (around -3 dBm). As expected distortion occurs at either bias extreme.

Fig. 9 shows scope traces of the output light with the VCSEL driven with a 10 GHz square wave and at different bias levels. The top trace shows operation at a point too close to the threshold current, resulting in severe distortion. The middle trace shows operation at an idle current which is
more suitable, though ringing still occurs due to
the limited optical damping at low drive currents.
Finally, the lower trace shows operation a 3 mA
bias current which results in a faithful
reproduction of the drive signal.

![Graph](image)

**Fig. 8.** Measured linear (5.01 GHz) and 3rd order
(5.02 GHz) product versus unmatched average
input power.

Fig. 10 shows an eye diagram at 10 Gbps (2^8-1
sequence) with a reasonable eye width. Part of the
noise seen in Fig. 10 is electrical noise caused the
measurement system (detector is operated directly
into the oscilloscope).

![Eye Diagram](image)

**Fig. 10.** Eye diagram of a VCSEL driven at
10 Gbps by a 50Ω impedance ECL-level source.
DC bias level was 3 mA.

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